IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| In re Application of: |) | |
|---------------------------------------------------------------------------------------------------------------------|-------------|-------------------------------------------------------|
| SEIICHI TAMURA ET AL. | :) | Examiner: Not Yet Assigned Art Unit: Not Yet Assigned |
| Application No.: Not Yet Assigned (National Phase of Int'l Application No. PCT/JP2005/008467, filed April 27, 2005) | ; ;) | The Ollie Too Too Pissigned |
| Filed: Concurrently Herewith |) | |
| For: PHOTOELECTRIC CONVERSION DEVICE AND MANUFACTURING METHOD THEREOF |) :) | September 26, 2006 |

Mail Stop: PCT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

In compliance with the duty of disclosure under 37 C.F.R. § 1.56 and in accordance with the practice under 37 C.F.R. §§ 1.97 and 1.98, the Examiner's attention is directed to the documents identified on the enclosed Form PTO-1449. Copies of those documents are also enclosed, except for the U.S. published patent applications.

For the concise explanation of relevance for the non-English documents, Japanese Patent Application Laid-Open Nos. 8-213582, 4-284625, and 1-243462, and Japanese Patent Application Nos. 2005-191362, 2002-164527, and 2002-110955, the Examiner is referred to the accompanying English abstracts, and to the PCT International Search Report mailed August 23, 2005, for International Application No. PCT/JP2005/008467, of which this application is the U.S. national phase. A copy of that Search Report is also enclosed.

It is respectfully requested that the above information be considered by the

Examiner and that a copy of the enclosed Form PTO-1449 be returned indicating that such

information has been considered.

Applicants' undersigned attorney may be reached in our New York office by

telephone at (212) 218-2100. All correspondence should continue to be directed to our

address given below.

Respectfully submitted,

/John A. Krause/ John A. Krause **Attorney for Applicants**

Registration No. 24,613

FITZPATRICK, CELLA, HARPER & SCINTO

30 Rockefeller Plaza

New York, New York 10112-3800

Facsimile: (212) 218-2200

NY MAIN 593806v1

- 2 -

| FORM PTO 144 | U.S. D | fied) EPARTMENT OF COMMERCE NT AND TRADEMARK OFFICE | | ATT | Y DOCKET NO. 03500.109226. | 1 | TION NO. N.Y lational Pha IP/2005/008 | ase Of |
|----------------------|--------|--------------------------------------------------------------|----------|----------|---------------------------------------------------|-------|---------------------------------------------|---------------------------------------|
| LIST | OF REF | ERENCES CITED BY APPLICANT(S) e several sheets if necessary) | | APPI | LICANT SEIICHI TAMU | | | 401 |
| | | | | FILIN | NG DATE | KAEI | GROUP | |
| | | | | | Concurrently Herewith | | | Assigned |
| | | | | U.S. P/ | ATENT DOCUMENTS | | | |
| *EXAMINER INITIAL | | DOCUMENT NUMBER | DATE | ≣ | NAME | CLASS | SUBCLASS | FILING DATE IF APPROPRIATE |
| | | 2002/0036303 A1 | 03/28/ | 02 | Ohkubo | 257 | 215 | |
| | | 2002/0024071 A1 | 02/28/ | 02 | Kawajiri et al. | 257 | 292 | |
| | | | | | | | | |
| | | | | | | | | |
| | | | | | | | | |
| | | | | | | | | |
| | | | | | | | | |
| | | | FC | REIGN | PATENT DOCUMENTS | | | |
| | | DOCUMENT NUMBER | DATE | Ē | COUNTRY | CLASS | SUBCLASS | TRANSLATION YES/NO/ OR ABSTRACT |
| | JP | 8-213582 A | 08/20/ | 96 | Japan | | | Abstract |
| | JP | 4-284625 A | 10/09/ | 92 | Japan | | | Abstract |
| | JP | 1-243462 A | 09/28/ | 89 | Japan | | | Abstract |
| | JP | 2005-191362 A | 07/14/ | 05 | Japan | | | Abstract |
| | JP | 2002-164527 A | | | Japan | | | Abstract |
| | JP | 2002-110955 A | | | Japan | | | Abstract |
| | | | | | | | | |
| | | OTHER DO | CUMENT(S |) (Inclu | iding Author, Title, Date, Pertinent Pages, Etc.) | | | |
| | | | | | | | | |
| | | | | | | | | |
| EXAMINER | | | | | DATE CONSIDERED | | | |

|--|

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.